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APPLICATION NO. FILING DATE		FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/605,238	09/17/2003	Min-Yi Hsu	11285-US-PA 3285		
31561	7590 03/22/2005		EXAMINER		
	'UN INTELLECTUAL	SMITH, BRADLEY			
	7 FLOOR-1, NO. 100 ROOSEVELT ROAD, SECTION 2			PAPER NUMBER	
TAIPEI, 100 TAIWAN			2891		
IAIWAN			DATE MAILED: 03/22/2009	DATE MAILED: 03/22/2005	

Please find below and/or attached an Office communication concerning this application or proceeding.

		Ap	plication No.	Applicant(s)	Applicant(s)			
Office Action Summary		10	/605,238	HSU ET AL.				
		Ex	aminer	Art Unit				
			adley K. Smith	2829				
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply								
THE - Exte after - If the - If NO - Failu Any	ORTENED STATUTORY PERIOD FOR MAILING DATE OF THIS COMMUNICATION of time may be available under the provisions of SIX (6) MONTHS from the mailing date of this communication period for reply specified above is less than thirty (30) do period for reply is specified above, the maximum statute re to reply within the set or extended period for reply will, reply received by the Office later than three months after end patent term adjustment. See 37 CFR 1.704(b).	ATION. 7 CFR 1.136(a). cation. ays, a reply within ory period will app by statute, cause	In no event, however, may a reply be the statutory minimum of thirty (30) by and will expire SIX (6) MONTHS fr the application to become ABANDO	timely filed  days will be considered time om the mailing date of this of NED (35 U.S.C. § 133).	ely. communication.			
Status								
1)	Responsive to communication(s) filed of	on						
2a)□	☐ This action is FINAL. 2b) ☐ This action is non-final.							
3)□	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.							
Disposition of Claims								
5)□ 6)⊠	4) ☐ Claim(s) 1-19 is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration.  5) ☐ Claim(s) is/are allowed.  6) ☐ Claim(s) 1-4,8,10,12,13 and 18 is/are rejected.  7) ☐ Claim(s) 5-7,9,11,14-17 and 19 is/are objected to.							
Applicati	on Papers							
10)⊠	The specification is objected to by the E The drawing(s) filed on <u>17 September 2</u> Applicant may not request that any objectio Replacement drawing sheet(s) including the The oath or declaration is objected to by	2003 is/are: n to the draw e correction is	ing(s) be held in abeyance. So required if the drawing(s) is	See 37 CFR 1.85(a). objected to. See 37 C	FR 1.121(d).			
Priority u	ınder 35 U.S.C. § 119							
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).  a) All b) Some * c) None of:  1. Certified copies of the priority documents have been received.  2. Certified copies of the priority documents have been received in Application No  3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).  * See the attached detailed Office action for a list of the certified copies not received.								
Attachmen	E(s)							
1) Notice of References Cited (PTO-892) 4) Interview Summary (PTO-413)								
3) 🔲 Inforn	e of Draftsperson's Patent Drawing Review (PTO- nation Disclosure Statement(s) (PTO-1449 or PTO r No(s)/Mail Date		Paper No(s)/Mail 5)	l Patent Application (PT	O-152)			

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#### **DETAILED ACTION**

### Specification

1. The title of the invention is not descriptive. A new title is required that is clearly indicative of the invention to which the claims are directed.

#### Claim Rejections - 35 USC § 102

2. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 3. Claims 1-3 are rejected under 35 U.S.C. 102(b) as being anticipated by Yang et al. (US Patent 5,827,437). Yang et al. disclose the method comprising: performing a dry etching process for removing the antireflective layer (108), removing the conductive layer (106), and removing the barrier layer (104) (columns 1-3 and figures 1a and 1b). With regards to claim 2, Yang et al. disclose the anti-reflective layer being made of TiN and being etched with Cl<sub>2</sub> (see columns 1-3). With respect to claim 3, Yang et al. disclose the use of CHF<sub>3</sub> (see column 9 lines 25-35).

## Claim Rejections - 35 USC § 103

- 4. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

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wet etching will isotropically etch the conductive layer.

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5. Claims 4, and 12 are rejected under 35 U.S.C. 103(a) as being unpatentable over Yang et al. (US Patent 5,827,437) in view of Chen et al. (US Patent 6,753,249). Yang et al. disclose the method comprising: performing a dry etching process for removing the antireflective layer (108), removing the conductive layer (106), and removing the barrier layer (104) (columns 1-3 and figures 1a and 1b). However Yang et al. fail to disclose the wet etch in order to remove the conductive layer. Where as Chen et al. disclose the removal of the conductive layer by wet etching (column 5 lines 18-30). Therefore it would have been obvious to one of ordinary skill in the art at the time the invention was made to combine the teachings of Yang et al. and Chen et al. because

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6. Claims 4, 8, 10, 12, 13, and 18 are rejected under 35 U.S.C. 103(a) as being unpatentable over Yang et al. (US Patent 5,827,437) in view of Chen et al. (US Patent 6,753,249). Yang et al. disclose the method comprising: performing a dry etching process for removing the antireflective layer (108), removing the conductive layer (106), and removing the barrier layer (104) (columns 1-3 and figures 1a and 1b). However Yang et al. fail to disclose the chemical mechanical polishing (CMP) step in order to remove the barrier layer (with respect to claim 8, and the wet etching step of the conductive layer). Where as Chen et al. disclose the removal of the barrier layer by CMP (and the wet etching step) (see column 5 lines 30-45). Therefore it would have been obvious to one of ordinary skill in the art at the time the invention was made to combine the teachings of Yang et al. and Chen et al. because with CMP one can

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precise detect the when the barrier layer has been removed and with a wet one can etch the conductive layer isotropically.

#### Allowable Subject Matter

- 7. Claims 5-7, 9, 11, 14-17, 19 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.
- 8. The following is a statement of reasons for the indication of allowable subject matter: the prior art of record neither teaches nor suggests the wet etching the conductive layer with sulfuric acid (claims 5, 6, 15, 16) etching the conductive layer with nitric acid (claims 7, and 17) the slurry containing aluminum oxide and hydrogen peroxide (claims 9, 11, 14, and 19).

#### Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Bradley K. Smith whose telephone number is (571) 272-1884. The examiner can normally be reached on 10-6 Monday through Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Bill Baumeister can be reached on (571) 272-1722. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Brad Smith

Primary Examiner
Art Unit 2829